In the Claims

Claim 1 (original): A nickel-vanadium sputtering component structure comprising at least 99.99 weight%, excluding gases, nickel and vanadium.

Claim 2 (original): The sputtering component structure of claim 1 being at least 99,995 weight%, excluding gases, nickel and vanadium.

Claim 3 (original): The sputtering component structure of claim 1 being at least 99.999 weight%, excluding gases, nickel and vanadium.

Claim 4 (original): The sputtering component structure of claim 1 as a sputtering target structure.

Claim 5 (original): The sputtering target structure of claim 4 as a sputtering target pre-fab.

Claim 6 (original): The sputtering target structure of claim 4 as a sputtering target.

Claim 7 (original): A nickel/vanadium sputtering component structure comprising at least 99.99 weight%, excluding gases, nickel and vanadium and having an average grain size throughout the structure of less than or equal to about 40 microns.

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Claim 8 (original): The nickel/vanadium sputtering component structure of claim 7 as a sputtering component pre-fab.

Claim 9 (original): The nickel/vanadium sputtering component structure of claim 7 as a sputtering component.

Claim 10 (original): The nickel/vanadium sputtering component of claim 9 wherein the average grain size is less than or equal to about 30 microns.

Claim 11 (original): The nickel/vanadium sputtering component of claim 9 wherein the average grain size is less than or equal to about 20 microns.

Claim 12 (original): The nickel/vanadium sputtering component of claim 9 comprising from about 4 weight percent vanadium to about 10 weight percent vanadium.

Claim 13 (original): The nickel/vanadium sputtering component of claim 9 comprising about 7 weight percent vanadium.

Claim 14 (original): The nickel/vanadium sputtering component of claim 9 as a sputtering target.

Claim 15 (original): A layer sputter-deposited from the sputtering target of claim 14.

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Claim 16 (original): The nickel/vanadium sputtering component of claim 9 comprising at least 99.995 weight%, excluding gases, nickel and vanadium.

Claim 17 (original): The nickel/vanadium sputtering component of claim 16 wherein the average grain size is less than or equal to about 30 microns.

Claim 18 (original): The nickel/vanadium sputtering component of claim 16 wherein the average grain size is less than or equal to about 20 microns.

Claim 19 (original): The nickel/vanadium sputtering component of claim 16 comprising from about 4 weight percent vanadium to about 10 weight percent vanadium.

Claim 20 (original): The nickel/vanadium sputtering component of claim 9 comprising at least 99.999 weight%, excluding gases, nickel and vanadium.

Claim 21 (original): The nickel/vanadium sputtering component of claim 20 wherein the average grain size is less than or equal to about 30 microns.

Claim 22 (original): The nickel/vanadium sputtering component of claim 20 wherein the average grain size is less than or equal to about 20 microns.

Claim 23 (original): The nickel/vanadium sputtering component of claim 20 comprising from about 4 weight percent vanadium to about 10 weight percent vanadium.

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Claims 24-39 (canceled).